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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/766,103	01/27/2004	Willie W. Ng	B-4585 619759-6	2200
Dichard D Bar	7590 02/15/2007	EXAMINER		
Richard P. Berg, ESQ. c/o LADAS & PARRY			VAN ROY, TOD THOMAS	
Suite 2100 5670 Wilshire	Boulevard	ART UNIT	PAPER NUMBER	
	CA 90036-5679	2828		
SHORTENED STATUTORY PERIOD OF RESPONSE		· MAIL DATE	DELIVERY MODE	
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Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

		<i>—————————————————————————————————————</i>
	Application No.	Applicant(s)
	10/766,103	NG ET AL.
Office Action Summary	Examiner wyst	Art Unit
	Tod T. Van Roy	2828
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	correspondence address
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DARWING STATE OF THE MAILING DARWING STATE OF THE MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tinuity will apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONE	N. nely filed the mailing date of this communication. D (35 U.S.C. § 133).
Status		
Responsive to communication(s) filed on <u>17 N</u> This action is FINAL . 2b)⊠ This Since this application is in condition for alloware closed in accordance with the practice under E	action is non-final. nce except for formal matters, pro	
Disposition of Claims		
4) Claim(s) 1,3-17 and 19-26 is/are pending in the 4a) Of the above claim(s) is/are withdraw 5) Claim(s) is/are allowed. 6) Claim(s) 1,3-17,19-23 and 26 is/are rejected. 7) Claim(s) 24 and 25 is/are objected to. 8) Claim(s) are subject to restriction and/or are subject to restriction and/or are subjected to by the Examine 10) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) accomposition and request that any objection to the	wn from consideration. r election requirement. r. epted or b) objected to by the drawing(s) be held in abeyance. Se	e 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex	• •	•
Priority under 35 U.S.C. § 119	of.	
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority document * See the attached detailed Office action for a list 	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	ion No ed in this National Stage
Attachment(s) Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 10/12/2006.	4) Interview Summary Paper No(s)/Mail D 5) Notice of Informal F 6) Other:	ate

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DETAILED ACTION

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 11/17/2006 has been entered.

Claim Rejections - 35 USC § 112

The examiner agrees that all previous USC 112 rejections were made improperly and are hereby withdrawn.

Response to Arguments

Applicant's arguments with respect to claim 17 have been considered but are moot in view of the new ground(s) of rejection.

Applicant's arguments, see Remarks, filed 11/17/2006, with respect to the rejections over Soref have been fully considered and are persuasive. The rejection of the claims has been withdrawn.

The examiner agrees that Soref does not properly motivate the use of silicon waveguides and substrate.

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Allowable Subject Matter

The indicated allowability of claim 26 is withdrawn in view of the newly discovered reference(s) to Orenstein. Rejections based on the newly cited reference(s) follow.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

- 1. Determining the scope and contents of the prior art.
- 2. Ascertaining the differences between the prior art and the claims at issue.
- 3. Resolving the level of ordinary skill in the pertinent art.
- 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

Claims 1, 5-10, and 13-16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Orenstein et al. (US 6940878) in view of Yamada et al. (US 6027254).

With respect to claim 1, Orenstein teaches (fig.3a), a reconfigurable laser transmitter comprising: an integration platform having a substrate (fig.3a), a gain element (col.3 lines 36-37) having an optical output, the gain element having a body of

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material different from said integrating platform (active layer would inherently be a different body of material in order to lase), being disposed on said integration platform, a first optical path (fig.3a laser WG) receiving optical output from said gain element, said first optical path comprising a waveguide (laser WG) within said integration platform, a tunable microresonator (fig.3a A) optically coupled with said first optical path, a second optical path coupled with said tunable microresonator, said second optical path comprising a waveguide (fig.3a upper), and a fixed grating (fig.3a B) in said integration platform (col.5 lines 4-5, on waveguide so in platform) and coupled with said second optical path. Orenstein does not teach the waveguides and substrate to be of silicon material. Yamada teaches a gain medium integrated onto a silicon substrate and using silicon waveguides (fig.9). It would have been obvious to one of ordinary skill in the art at the time of the invention to combine the substrate and waveguide material of Yamada with the transmitter of Orenstein in order to allow for heat dissipation through the substrate (Yamada, col.1 lines 40-52), as well as to use silicon waveguides as this well known waveguiding material (optical fibers) is a low loss transmitter of a plurality of wavelengths which would function well in Orenstein's tunable system.

With respect to claim 5, silicon inherently has a temperature sensitivity of less than 0.1A/C (approx. 0.01 A/C, see Conradi US 6061369).

With respect to claims 6-7, Orenstein teaches electrical (Vernier) tuning (col.3 lines 60-63).

With respect to claim 8, Orenstein teaches the use of a sampled grating (col.3 lines 45-48).

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With respect to claim 9, Orenstein teaches the gain element is a laser and the grating is used for locking the laser thereto (col.1 lines 31-37).

With respect to claim 10, Orenstein and Yamada teach the transmitter as outlined in the rejection of claims 1 and 9 above, and Orenstein additionally teaches the microresonator is mounted on the integration platform.

With respect to the UV-induced limitation found in claim 10, these limitations merely detail the methods of forming the device. The method of forming a device is not germane to the patentability of the device itself, therefore these limitations are not given patentable weight. At best these claims could be characterized as product-by-process claims, where the process limitations are not limiting, only the structure implied by the process. See MPEP 2113. Here, the structure implied by the process steps is merely the structure of claim 10.

Claims 13-16 are rejected for the same reasons outlined in the rejections to claims 6, 5, 8, and 7 respectively.

Claims 3 and 11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Orenstein, Yamada, and further in view of Soref (US 6195187).

With respect to claims 3 and 11, Orenstein and Yamada teach the transmitter outlined in the rejections to claims 1 and 10 below, but do not teach the use of a microdisk. Soref teaches a coupling device (between two waveguides) which uses a microdisk. It would have been obvious to one of ordinary skill in the art at the time of the

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invention to replace the microring of Orenstein and Yamada with the microdisk of Soref in order to obtain a more favorable contact geometry (Soref, col.5 lines 60-64).

Claims 17, 19-23 and 26 are rejected under 35 U.S.C. 103(a) as being unpatentable over Orenstein, Yamada, Soref, and further in view of Tanaka et al. (US 6320888).

With respect to claim 17, Orenstein, Yamada, and Soref teach the transmitter outlined in the rejections to claims 1, 3, and 6 above, but do not teach the grating to be formed in the waveguide. Tanaka teaches a gain medium and silicon waveguide integrated on a silicon substrate (fig.1) wherein the grating is written directly unto the waveguide. It would have been obvious to one of ordinary skill in the art at the time of the invention to combine the transmitter and separated waveguide/grating of Orenstein, Yamada, and Soref with the combined waveguide/grating of Tanaka in order to reduce the amount of loss due to evanescent coupling when using an external grating.

Claim 19 is rejected for the same reasons as claim 7 above.

Claim 20 is rejected for the same reasons as claim 9 above.

With respect to the UV-induced limitation found in claim 21, these limitations merely detail the methods of forming the device. The method of forming a device is not germane to the patentability of the device itself, therefore these limitations are not given patentable weight. At best these claims could be characterized as product-by-process claims, where the process limitations are not limiting, only the structure implied by the

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process. See MPEP 2113. Here, the structure implied by the process steps is merely the structure of claim 17.

With respect to claim 22, Orenstein further teaches the step of coupling a fixed optical resonator filter (B) to said tunable microresonator (A) (see figs.4a/b).

With respect to claim 23, Orenstein further teaches emitting light at 1.55um (col.3 lines 29-42, an international standard for silicon waveguides (fibers)).

With respect to claim 26, Orenstein further teaches forming another waveguide in the integration platform (either WG or upper). Orenstein does not teach the microresonator to be of III-V materials. These materials are known in the art to be used with semiconductor lasers and resonators. It would have been obvious to one having ordinary skill in the art at the time the invention was made to make the resonator of these known materials, since it has been held to be within the general skill of a worker in the art to select a known material on the basis of its suitability for the intended use as a matter of obvious design choice. *In re Leshin*, 227 F.2d 197, 125 USPQ 416 (CCPA 1960).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Tod T. Van Roy whose telephone number is (571)272-8447. The examiner can normally be reached on M-F:

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Minsun Harvey can be reached on (571)272-1835. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

TVR

MINSUN OH HARVEY
PRIMARY EXAMINER